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It's a trap! On the nature of localised states and charge trapping in lead halide perovskites

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The recent surge of scientific interest for lead halide perovskite semiconductors and optoelectronic devices has seen a mix of materials science sub-fields converge on the same “magical” crystal structure. However, this has ultimately shaped some ambiguity in the definitions shared between researchers across different research areas. For example, scientists aiming to decipher the nature of localized states within metal halide perovskites sometimes over simplify the problem, using identifiers such as “defects” or “states”. Herein, we review the topic of charge carrier trapping within lead halide perovskites, overviewing their causes and influences, as well as specifying their potential resolutions. We assess the popular lead triiodide perovskites for case study and examine the origins of both intrinsic and extrinsic defects leading to charge carrier trapping in performant perovskite-based solar cells, and review the state-of-the-art actions being taken to limit their effects and achieve world-record conversion efficiencies. Finally, we also draw brief comparisons to other emerging lead-free systems and highlight promising optical tools and design principles moving forward.

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Introduction

The on-going expansion of new electronic materials and technologies which source, detect and control light has reshaped human existence across the globe. As such, the development of new optoelectronic materials will continue into the foreseeable future. For now, the recent renaissance of cheap and solution processable lead halide perovskite (LHP) semiconductors (general formula ABX_3 ; where A = Cs, formamidinium; FA, methylammonium; MA, B = Pb, X = Cl, Br, I) has fuelled intense research into exploring how to make them commercially viable and bring them to market.^{1,2} Within the laboratory, hybrid perovskite-based solar cells have already achieved conversion efficiencies similar to commercialized solar cell technologies,³ far beyond what was previously expected for devices based on a polycrystalline solution processed absorbing layer.⁴ This is because solution-processed semiconductors are generally low-quality and poor performing, due to an abundance of crystal defects. High performance solar cells require the efficient transport and extraction of the photo-generated charges (electrons and holes), features which are strongly impacted by structural defects.

Ideally, each atom in a periodic crystal lattice will be located at its designated position and any deviation from this results in a defect. Structural non-periodicity introduces disorder into the lattice bonding and orbital configuration, impacting the properties of free carriers moving through these orbitals. This concept is illustrated in Fig. 1a for a general case, where crystalline imperfections form localized electronic states at energy levels different to the carrier transport bands, providing means for (photo-)generated free carriers to energetically fall into and get trapped (Fig. 1b). Charges which get trapped thus have their mobility and movement restricted in the crystal. The existence of an additional energy barrier between the charge delocalized in the transport energy band and localized on a defect is also shown in Fig. 1a, arising from the difference in the equilibrium nuclear configurations between empty and occupied defect energy states.^{5,6} Once the free charge is captured and localised at a defect site, its fate will depend on the nature of the trap and can widely vary. For example, trapped carriers can escape back into the excited transport levels by taking on additional energy (activation energy), *via* further optical excitations or by absorbing thermal energy ($k_B T \sim 26$ meV at room temperature, where k_B and T represent the Boltzmann constant and temperature, respectively). Not all defects introduce carrier trapping; if a defect energy level resides above or below the conduction band (CB) and valence band (VB) edges, respectively, the defect state is typically considered harmless. Though levels residing between the band edges (*i.e.* in the energy gap) can trap charges, with a trap depth defined by the energy difference between the transport

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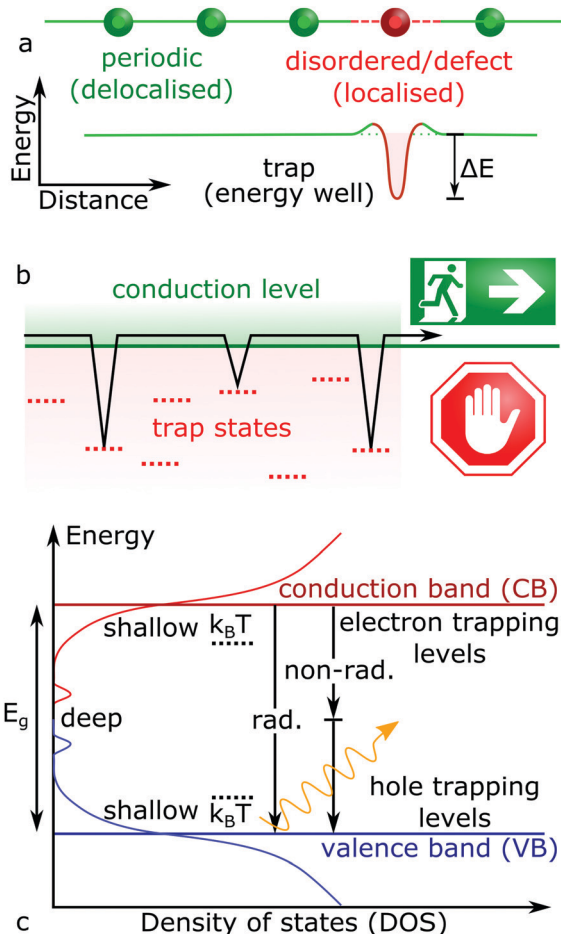


Fig. 1 (a) Scheme of a charge localization caused by non-periodic disorder and defect in a semiconductor lattice (top), which introduce new energetic levels (bottom). (b) Scheme of charge trapping kinetics, where trap slow down charge carrier transport through trapping and detrapping events, as described by eqn (1). (c) Schematic representation of state density in a disordered semiconductor, whereby both band-to-band radiative (rad.) and non-band-to-band non-radiative (non-rad.) recombination (vertical arrows) can occur.

states and the defect levels (ΔE). In Fig. 1c, so-called shallow traps will involve a relatively small difference in energy away from their respective conduction/valence band edges ($\Delta E \leq k_B T$), while deep traps exist toward the middle of the semiconductor bandgap ($\Delta E > k_B T$). Typically, shallow traps will only restrict the efficient movement of free charges through trapping and detrapping processes, while deep traps hinder detrapping and can facilitate non-radiative recombination pathways (Fig. 1c).

The concentration of different defect types is determined by the enthalpy of their formation and the growth temperature.⁷ Despite the overwhelming advantages of LHPs, their ‘soft’ crystal lattice, and subsequent low defect formation energies,⁸ are expected to introduce relatively large concentrations of defects, which usually is detrimental to performance. However, the defect energy levels in LHPs favour the formation of relatively shallow and even benign states, making LHPs relatively tolerant⁹ to imperfections. Within this context, it is the unique ability to solution process high performance LHPs which is key to realizing their full potential, allowing for facile production options

which are simply not paralleled elsewhere within semiconductor research. This difference is important because the performance of other common semiconducting materials branches¹⁰ (e.g. Si, Ge, and the III–Vs) are relatively sensitive to structural defects and must be grown under tightly controlled conditions (e.g. pure vapour deposition or high-vacuum epitaxy techniques).

The density of traps per unit volume and their relative energy in the electronic band structure strongly influence device performance, e.g. an increase in trap density and ΔE (towards mid-bandgap) directly decreases the carrier mobility and drops the open circuit voltage in solar cells.¹¹ The trap density in LHPs has been shown to strongly depend on the (post-)processing procedures (such as annealing) employed,^{12,13} causing inconsistencies across different studies of the same material. Needless to say, the ongoing management and mitigation of parasitic defects (*i.e.* traps) in LHPs represents a scientifically challenging and technologically important task for researchers.¹⁴ Reducing their negative influence will ultimately lead to enhanced optoelectronic performance; for example, an almost trap-free LHP has been achieved in CsPbI₃ quantum dots (QDs), yielding near unity photoluminescence quantum yields.¹⁵ Such trap-free conditions are reached by effective surface trap passivation (making the QD surface states unreactive) and by the improbability of a single bulk defect to be present per crystal (< 10 nm). It is the aim of this review to clearly lay out the unique nature of charge trapping within lead halide perovskites, evaluate the current state of play within the field, and detail recent works which have aimed to identify their intrinsic and extrinsic origins, impacts and solutions.

Discussion

Influence of charge trapping

Under the influence of an electric field, charges in semiconductors drift according to the field direction through the crystal. This motion, however, is disturbed by scattering from phonons and lattice defects. Also charge carrier motion can be stopped by their capture on localized trapping states (Fig. 1b). Obviously, the captured charges do not contribute to net carrier transport while trapped. When captured on shallow traps at non-zero temperatures a charge can be thermally excited back to the transport band (above the so-called mobility edge) allowing it to contribute again to the net charge transport. Higher densities of free carriers in the system can also fill the traps with charges and increase the average charge mobility. Thus, the charge mobility of a semiconductor is a complex function of charge carrier concentration, trap types and their densities, thermal energies, the presence of scattering sites, and so on.

In the presence of shallow traps, the multiple trapping and release (MTR) model is widely employed to describe charge mobility in crystalline semiconductors at room temperature. The effective mobility (μ_{eff}) is proportional to the trap-free mobility (μ_0), reduced by the fraction of temporal trapping events:

$$\mu_{\text{eff}} = \mu_0 \left(\frac{\tau(\text{free})}{\tau(\text{free}) + \tau(\text{trap})} \right). \quad (1)$$



Here $\tau(\text{trap})$ and $\tau(\text{free})$ define the average time spent by carriers in traps and clean transport states, respectively. For efficient solar cells, the influence of traps in eqn (1) must be optimized through minimizing $\tau(\text{trap})$. Charge trapping is most influential while the system is illuminated by relatively low-intensity light, as higher intensities increase the concentration of excited carriers which fill the traps, reducing their influence on the carrier transport. Regarding the mean free carrier lifetimes (τ) in LHPs, the interested reader is referred to ref. 16 for a useful overview.¹⁶

In addition, trapped charge carriers can be lost *via* trap-mediated non-radiative recombination (Fig. 1c), which decreases the energy conversion efficiency. This happens *via* trap states lying close to the middle of the bandgap (*i.e.* $\Delta E \gg k_B T$). Indeed, deeply trapped electrons (holes) cannot be thermally excited back to the conduction band because the energy requirement makes the transition highly improbable, maximizing the probability of its non-radiative recombination with a hole (electron).

Non-radiative recombination is a highly parasitic process for solar cells because it limits the carrier diffusion length (L_D) which, for a device to efficiently operate, should exceed the perovskite film thickness in order to be extracted. The diffusion length squared is proportional to the mobility mean (μ) and lifetime (τ) of charge e :

$$L_D = \left(\frac{\mu k_B T}{e} \right)^{1/2} \quad (2)$$

For perovskite MAPbI₃, the diffusion length is in the order of hundreds of nanometers to microns,¹⁷ which makes efficient solar cells possible. It is only deep traps causing non-radiative recombination which are detrimental for charge extraction. In general, shallow traps merely reduce mobility and delay

the extraction process, and can suppress the maximum current density supported by the device.

Determining the nature of traps

Several types of defects are commonly identified within semiconductor crystals, being illustrated in Fig. 2(a) for the general ABX₃ perovskite system.²⁰ The imperfections shown in Fig. 2(a) are divided into two categories: intrinsic and extrinsic. Extrinsic surface defects – caused by the surrounding environment or unsaturated surface bonds – are a major concern in LHPs, as solution processed thin films often form grainy, polycrystalline networks. Intrinsic (or native) point defects are commonly branded using Kröger–Vink notation, whereby label M_S identifies both the defective species (M) and lattice site (S). For instance, lead occupying an iodide site yields an anti-site label of Pb_I. The electronic band structure of LHPs is derived from the electronic Pb–X sub-lattice and most trap states will be directly linked to the energy levels created at improper bonding at these respective sites. For example, Fig. 2b shows how a bear X-terminating surface forms traps due to a lack of local stoichiometric composition and improper surface bonding (left), which can be mitigated by introducing a passivator (*i.e.* surface chemical treatment). For an effective passivation, new chemical bonds formed at the Pb–X-derived surface orbitals shift the defect level either toward or into the band edges, reducing the negative influence of the defect.

Solution-processed LHPs maintain relatively low trap densities²¹ in both polycrystalline (10¹⁶–10¹⁷ cm⁻³) and single crystalline (10⁹–10¹¹ cm⁻³) systems. An overview of the ranges determined experimentally for common lead halide perovskites²² is provided in Table 1. Compared to more traditional semiconductors, the values measured from LHP systems are fairly comparable; typical trap densities in polycrystalline²³ (10¹³–10¹⁴ cm⁻³) and

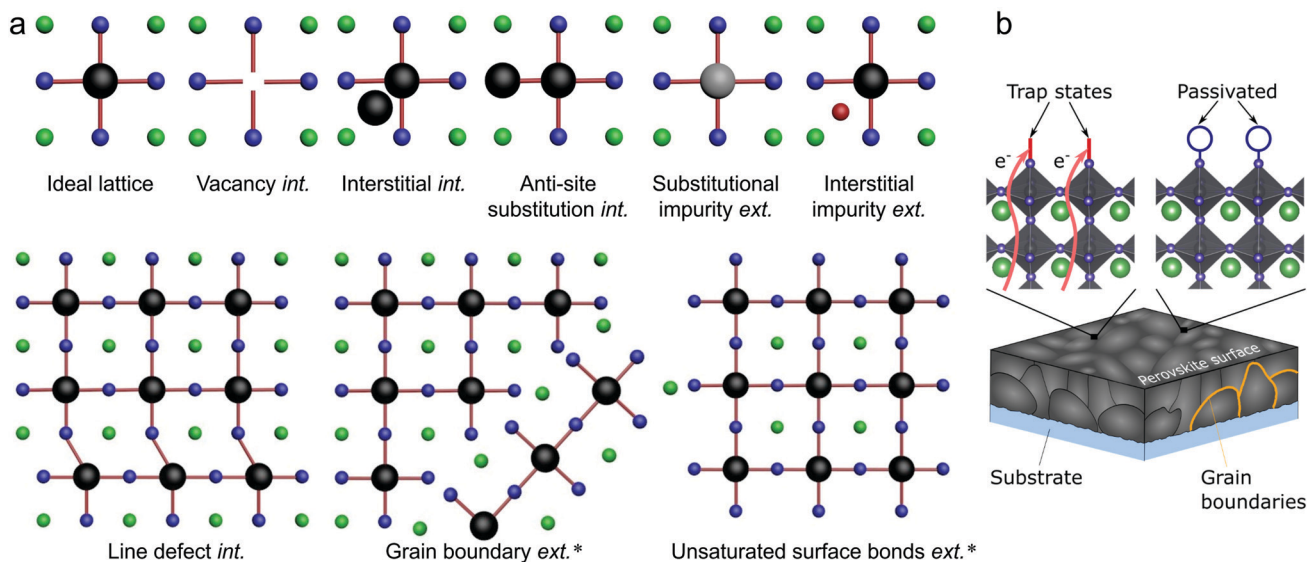


Fig. 2 (a) Schematic overview of intrinsic (int.) and extrinsic (ext.) defect types in LHPs, relative to an ideal lattice. Defects which have been identified experimentally^{18,19} are indicated by *. (b) Schematic illustration of parasitic recombination at surface traps (and subsurface traps) being passivated by introducing additional atoms/molecules (blue circle) which binds to improperly bound orbitals, which cause the trap state. For all structures, the green, black and blue spheres represent A, B and X elements, respectively, while the grey and red represent different impurities.



single crystal ($\sim 10^8 \text{ cm}^{-3}$)²⁴ Si, compared to popular high-purity II–VIs and III–Vs, like CdTe (10^{13} – 10^{16} cm^{-3}),^{25,26} CIGS (10^{11} – 10^{15} cm^{-3}),^{27,28} GaN ($\sim 5 \times 10^{15} \text{ cm}^{-3}$)²⁹ and GaAs (10^{13} – 10^{15} cm^{-3}).³⁰

Each experimental technique used to examine traps has its own advantages and limitations. The popular space charge limited current (SCLC) method³¹ is widely used for LHPs and provides many of the values in Table 1, offering a powerful method for unravelling carrier transport properties, like the carrier density, conductivity, mobility and trap concentration. However, while SCLC is widely used to characterise LHPs, trap concentrations determined in this way are imperfect, as the approach cannot discriminate between different kinds of charges generating the current.²² For example, LHPs have the potential for ion transport within the crystal, which leads to an underestimation of the trap concentration. This is particularly true for the relatively low trap concentration range (*i.e.* 10^8 – 10^9 cm^{-3}). Roughly speaking, if the concentration of mobile ions is enough, they can compensate the effect of traps on the current.

With the trap population experimentally evaluated, effort must be made toward understanding their cause. Theoretical calculations – including *ab initio* and density functional theory (DFT) methods – provide one of the most powerful and direct tools for exacting the nature and origin of traps. This is because it is practically impossible for experimental probes to reliably provide an atomistic picture of the imperfection, and thus must be complemented *via* predictive materials modelling. A classical

approach takes the form of calculating the energy level of the defect and comparing it to the calculated electronic band structure.³⁴ Though, depending on the calculation method employed, the reliability of DFT for investigating defect states still remains in question.^{37–39} For DFT calculations of defect energy levels, supercells are typically employed with a large number of atoms and high computational costs. This encourages the use of faster DFT routines, such as methods which exclude spin–orbit coupling (SOC), functionals which correct for self-interaction error and hybrid functionals (*i.e.* HSE-06 or PBE0), which contain a fraction of the Hartree–Fock exchange, as opposed to functionals which do not include it (*i.e.* generalized gradient approximations: GGA). Du *et al.* showed⁴⁰ that neglecting SOC and hybrid functions in some of the early DFT calculations reported for LHPs lead to incorrect predictions of the electronic band structure.⁴⁰ As an example, for MAPbI₃ GGA gives a gap of 1.6 eV, GGA + SOC gives 0.6 eV, HSE-06 gives 2.4 eV and HSE-06-SOC gives 1.6 eV. The value determined using HSE-06-SOC is accurate and places the relative band edge energies correctly, while GGA which gives the same gap though the wrong band energies (all levels are shifted up by roughly 0.5 eV), implying inaccurate defect levels. As such, Agiorgousis *et al.* reported³⁸ deep intrinsic defects in MAPbI₃, including iodine vacancies, while Du *et al.* claimed that iodine vacancy will only create shallow traps.³⁷ Ultimately, iodine vacancies were confirmed through reliable DFT calculations⁴⁰ to cause relatively shallow charge trapping.

Table 1 Overview of the calculated point defect traps and experimental evidence for lead halide perovskites and experimental remediation methods

Materials	Form (α phase)	Origins (calculation or experiments, trap density cm^{-3})	Solutions	
MAPbI ₃	Single crystal	N (MA _i , Pb _{MA} , V _I , Pb _i , MA _i , Pb _i) P (I _i , MA _{Pb} , V _{MA} , V _{Pb} , I _{MA} , I _{Pb}) First principle calculation ³⁵	Intrinsic defects ($n_{\text{electron}} = 4.8 \times 10^{10}$, $n_{\text{hole}} = 1.8 \times 10^9$) ³¹ ($n_{\text{trap}} = 3.3 \times 10^{10}$), ⁶³ (3.6×10^{10}) ⁶⁴ SCLC; (10^9 – 10^{10}) ⁶⁴ TAS	(Intrinsic) tuning compositional ratio; ¹³ K ⁺ doping; ⁶⁵ anti-solvent ⁶³
	Thin film	Intrinsic defects (5×10^{16}) and surface defects (1.6×10^{17}), ⁶⁶ (2.5×10^{17}), ⁶⁷ (10^{17} – 10^{18}), ⁶⁸ (6.7×10^{17}) ⁶⁹ PL; (10^{15} – 10^{17}), ⁷⁰ (10^{18} – 10^{19}) ⁷¹ TAS; (1.22×10^{16}) ⁷² SCLC; (10^{21}) ⁷³ TSC		(Extrinsic) surface passivation (fullerene, ⁷⁰ pyridine and thiophene ⁷⁴)
FAPbI ₃	Single crystal	N (FA _i , Pb _{FA} , V _I , Pb _i , FA _i , Pb _i) P (I _i , FA _{Pb} , V _{FA} , V _{Pb} , I _{FA} , I _{Pb}) First principle calculation ³²	Intrinsic defects (6.2×10^{11}), ⁷⁶ (1.13×10^{10}), ⁷⁷ (1.34×10^{10}) ⁷⁸ SCLC	(Intrinsic) introducing additional triiodide ions ⁵⁹
	Thin film	5.28×10^{14} DLTS measurement; ⁵⁹ (10^{17}) ⁶⁷ PL		(Extrinsic) surface passivation (phenylalkylamine ⁵⁹), using PMMA ⁸⁰
CsPbI ₂ Br	Thin film	(8×10^{16}), ⁸¹ (10^{15} – 10^{16}) ⁸² SCLC		(Extrinsic) Pb ²⁺ solution surface passivation ⁸¹
CsPbI ₃	Bulk	N (Pb _{Cs} , Cs _I , Pb _I , Cs _I , Pb _i , V _I)	—	(Intrinsic) use TOP-PbI ₂ as reactive precursor ¹⁵
		P (I _{Pb} , I _{Cs} , Cs _{Pb} , I _i , V _{Cs} , V _{Pb})		(Extrinsic) passivation (choline iodide, ⁷⁵ PVP ⁸³ and bidentate ⁸⁴ ligands)
		First principle calculation ⁴¹		
MAPbBr ₃	Single crystal	N (MA _i , Pb _{MA} , V _{Br} , Pb _i , MA _{Br} , Pb _{Br}) P (Br _i , MA _{Pb} , V _{MA} , V _{Pb} , Br _{MA} , Br _{Pb}) DFT calculation ³³	Intrinsic defects ($n_{\text{electron}} = 1.1 \times 10^{11}$, $n_{\text{hole}} = 2.6 \times 10^{10}$) ³¹ ($n_{\text{trap}} = 5.8 \times 10^9$) ⁶³ SCLC measurement; ($n_{\text{trap}} = 10^{15}$) ⁸⁵ PL measurement; ($n_{\text{trap}} = 10^9$) ⁸⁶ DLTS	(Intrinsic) tuning molar ratio; ⁸⁷ anti-solvent ⁶³ (Extrinsic) passivation (amine-based ⁸⁸ passivation)
		—	Intrinsic defects (9.6×10^9) ⁷⁷ SCLC measurement	(Intrinsic) rubidium doping ⁸⁹ (Extrinsic) organic ligands treatment ⁹⁰
CsPbBr ₃	Single crystal	N (Cs _{Br} , Cs _I , Pb _i , Pb _{Br} , Pb _{Cs} , V _{Br}) P (Br _{Cs} , Br _{Pb} , Cs _{Pb} , Br _i , V _{Cs} , V _{Pb}) First principle calculation ⁹	Intrinsic defects ($n_{\text{electron}} = 1.1 \times 10^{10}$, $n_{\text{hole}} = 4.2 \times 10^{10}$) ⁹¹ SCLC measurement	(Intrinsic) tuning precursor concentration ⁹² (Extrinsic) post synthesis treatment with lead bromide; ⁹³ thiocyanate ⁹⁴ surface passivation





Fig. 3 The calculated transition energy levels of intrinsic point defects^{9,32–36} in APbX₃ perovskites. The energy is determined relative to a zero-energy valence band for all materials, with the same color scheme used to show the position of the conduction band (semitransparent horizontal lines). The defect levels are identified in terms of the threshold energy to convert the system from charge state q to q' , in the format q/q' . For example, if q' is less (more) than q , the defect acts as an electron acceptor (donor), with the integer difference indicating the number of trapped charges. From left to right, the point defect types are placed in a general order of increasing formation energy.

Defect energy simulations for LHPs are relatively limited and there is certainly no systematic or complete set of results covering the different cation and halide compositions. Fig. 3 overviews the predicted energy levels for all 12 native point defects in lead halide perovskites, determined using DFT^{9,32–34,41,42} (with SOC where available^{9,41,42}). A central issue here is in the accuracy of the quantitative prediction of the band edges, which is essential to reliably estimating the relative defect energies. This problem is pronounced for the DFT calculation of the CsPbI₃ perovskite (with SOC), with the bandgap estimated at 1.02 eV,⁴¹ which is far less than experimental observations⁴⁴ (1.8 eV). Excluding SOC in the calculation leads to a larger bandgap energy of 2.0 eV,⁴⁴ highlighting the dependence of the result to the method employed.³⁹

Fig. 3 horizontally places the different defect types in LHPs roughly in order of increasing formation energy,^{39,45} *i.e.* or decreasing probability of forming within the crystal. In general, shallower traps are more inclined to arise from a vacancy and interstitial defects in LHPs, which typically have the smallest formation energy. Conversely, deep traps arising from anti-sites are likely to form less frequently. This helps to explain, in part, how even LHP polycrystalline thin films retain good optoelectronic properties, compared to their relatively less defective SC counterparts.

Intrinsic point defects and defect tolerance

Theoretical studies of LHPs have mainly focused on well-ordered structures, such as the well-defined α , β , γ and δ phases

of lead-based systems.⁴⁶ In reality, perovskite structures are inherently disordered and very complicated. This is particularly true when they are integrated into a mesoporous network, *e.g.* titania, alumina or any other substrate for device applications. It has been suggested that the majority of MAPbI₃ perovskite films integrated with mesoporous TiO₂ (70%) are disordered, where their local structural coherence extends over a range of only ~ 1.4 nm.⁴⁷ Even high-quality perovskites possess an intrinsic level of disorder on the same length scale, due to its soft crystal structure and complicated lattice dynamics.^{48–51} The dynamic disorder of LHP is related to local thermally driven distortions in the lead halide framework.⁵² Furthermore, there is evidence^{14,53} of a potential direct relation of ion migration with parasitic nonradiative recombination centers. Overviews of important studies identifying and controlling the ion migration process can be consulted in reviews.^{54,55} For example, the ultrasoft and polarisable lattice of the α -FAPbI₃ system produces polarons (through electron–phonon coupling) with a coherence length similar to the 1.4 nm described above, without any connection to the material being in a mesoporous matrix or not.⁵⁶

DFT is currently the most accepted technique for targeting and isolating the origin of point defects. As outlined above, such work has helped to reveal why LHPs exhibit a relatively strong tolerance to crystal defects and traps,³³ compared to more traditional semiconductors. Though, no reports have





Fig. 4 Comparison of typical trap energies relative to the electronic band structure of traditional defect intolerant compound semiconductors (*i.e.* III–V and II–VI varieties) and defect tolerant⁴³ lead halide perovskite materials.^{1,2}

managed a series of controlled and direct experimental results. DFT calculations suggest the relative energies for many intrinsic point defects in LHPs collect near to, or even inside, the electronic states forming the CB and VB (Fig. 4). This is because point defects which introduce deep mid-gap states (*i.e.* large ΔE) are unlikely to form, enabling reasonable carrier release energies and subsequently short trapping times at room temperature. The close proximity of defect energy levels^{57,58} in LHPs relative to the CB and VB is expected to arise from having molecular anti-bonding orbitals (which raise the energy of the orbitals) at the (valence band maximum) VBM, and bonding orbitals at the (conduction band minimum) CBM. This is in contrast to traditional semiconductors, which typically have the reverse orbital character. Taking an atomic vacancy as an example, this concept can be clarified; dangling bonds at a vacancy (of any type) establish levels inside the VB and near the CB,^{2,57,58} leaving the bandgap relatively clean. This argument can be extended to other types of intrinsic defects, such as interstitials and anti-sites, as well as the dangling bonds found at grain boundaries and surfaces. This is in contrast to more traditional defect intolerant systems like the classic III–V semiconductor band structures (Fig. 4), which are more prone to deep trap formation. According to the relative energy of the trap states in the bandgap, their characterization can be further subdivided into electron acceptors (p-type) and donors (n-type).

Table 1 provides a summary of point defect traps revealed in a variety of popular lead halide perovskite compositions. Through this table, common intrinsic trap types and their effects can be found, and used to predict the properties of other lead halide perovskites. For example, halide interstitials and the substitution for A cation and Pb typically induce hole traps (electron donors). In contrast, halide vacancies and A cation substitutions for halide usually induce electron traps (electron acceptors). Thus, the nature of traps within the electronic structure of performant lead halide (iodide-based) systems appears to be relatively consistent across varied cations compositions.

FAPbI₃-based perovskite materials have been involved with recent reports of high-performance perovskite solar cells, *i.e.* all devices exhibiting conversion efficiencies in excess of 18%^{59–61} (see Fig. 4). DFT modeling of FAPbI₃ has revealed that their intrinsic defects levels are relatively similar to those existing

in MAPbI₃.³² This is expected, given their common Pb–I hybridised electronic structure; the upper valence band is formed by Pb s and I p orbitals and the conduction band are predominantly made by the Pb p orbitals. However, weaker van der Waals interactions between the FA cations and the PbI₆ octahedra can create deep levels of FA-related traps (*e.g.*, FA_I and I_{FA}) in the band gap.³² Thus, the MA and FA A-site cations in perovskites do not directly contribute to the electronic states in the vicinity of the band edges. A-cation-related intrinsic defects (vacancies or substitutions) will not directly induce mid-gap traps, though can influence the defect formation energies of the nearby lead halide octahedral. Actually, A-site cation defects have an indirect effect on optical and electronic properties of perovskite materials by changing the lattice parameters or octahedral tilting, locally, thereby affecting the Pb–X sub-lattice.

Nonetheless, taking MA/FAPbI₃ mixed cation perovskites together as a joint case study, shallow traps, deep traps and trap levels induced by charged defects will exist to varying degrees. The ideal MAPbI₃ structure intrinsically exhibits twelve point defects including vacancies of MA, Pb and I, interstitial MA, Pb and I, and six substitutions being MA_{Pb}, Pb_{MA}, MA_I, Pb_I, I_{MA} and I_{Pb}. Despite competing interpretations,^{37–39,62} point defects in MAPbI₃ are expected to only induce shallow transition energy levels. Although, deep level trap states can form by I_I (iodide interstitial) in β -MAPbI₃.⁴⁰ Further, it has been shown that excess iodine, in the form of MAI and PbI₂ vacancies, do not create any parasitic trap states.²²

Charged point defects

The effects of charged defects, and specifically highly mobile ions, in MA/FAPbI₃ has become an important research topic and attracted recent attention.^{49,95} This is because the migration of ionic defects with low activation energies forms an intrinsic mechanism inside perovskites,⁹⁵ with the notable exception of Pb²⁺ migration⁴⁹ (activation energy is generally considered too large). Consequently, iodine vacancies (interstitials) in MAPbI₃ are particularly influential in optoelectronic devices, as they can easily diffuse through the perovskite crystal while exposed to an external bias.^{49,96,97} Charged defects are considered as the origin of elemental redistribution within perovskites and have been linked to local changes in density of states and electrical properties.⁵⁴ For instance, ion migration is the likely origin of the photocurrent hysteresis effect⁴⁹ and giant switchable photovoltaic effect⁹⁸ in solar cells. While charged migrating ions themselves do not necessarily contribute to charge trapping, LHPs are increasingly being considered as “soft” solids and such phenomenon contributes and complicates the environment in which defects form and influence carriers deep inside the crystal.⁹⁹

Formation and mitigation of intrinsic defects

The formation of point defects during perovskite growth are governed by the crystallisation kinetics and dynamics. The relationship between defects and the growth conditions has been extensively investigated and revealed to be highly multi-parameter problem. Together, the material stoichiometry, light



exposure, temperature, atmospheric humidity and pressure are all found to influence the formation of defects.^{12,100,101} Wang *et al.* demonstrated that both thermal treatments and tuning the molar ratio of the precursor agents (PbI₂ and MAI) during solution deposition can reduce the final trap density.¹⁰² Further, thermal annealing can also convert a p-type perovskite to n-type, by removing MAI. Conversely, the hole concentration can be reduced by adjusting the MAI concentration forming p- or n-type perovskites when applying a two-step solution process. Similar work is also reported by Divitini *et al.*¹⁰³ where they found that heat treatment can lead to iodine and lead migration under extremely high temperatures, stabilizing the perovskite layer. Further exposure to small amounts of oxygen can also help interstitial iodine oxidation and decrease deep level trap density.¹⁰⁴

Compositional alloying has proved an efficient way to suppress traps in LHPs through the possibility of phase separation into low defect phases.¹⁰⁵ Unfortunately, the exact nature of defects in alloyed perovskites are still unclear. In any case, it was recently reported that doping APbI₃ with alkali cations (Rb⁺, K⁺)^{106,107} has several beneficial effects to help mitigate defect formation and charge trapping. The introduced K⁺ can occupy interstitial sites in MAPbI₃ and create MA vacancies.^{65,108} As such, the presence of K⁺ can modify the physical and electrical properties and prevent iodide defect formation. Importantly, the hysteresis effect within solar cells can also be reduced by introducing K⁺ cations. It is further demonstrated that the optimized amount (20%) of K⁺ could help for improving crystallinity and decrease surface potential in MAPbI₃ films. In a similar fashion, halide doping with Br⁻ and Cl⁻ can effectively inactivate iodine hole traps.⁴²

Light soaking and trap filling

So-called “light soaking” effects – where the photovoltaic output is altered during light exposure – have been observed in a variety of solar cell technologies, influencing their long-term performance under illumination.¹⁰⁹ For instance, amorphous silicon (a-Si) exhibits a few percent decrease in PCE after the first hundred hours of light soaking due to defects created *via* breaking of the Si-Si bonds by the photo-excited carriers after thermalization.^{109–112} For the case of CdTe- and CIS/CIGS-based (*i.e.* Cu(In,Ga)Se₂ family) photovoltaics, light soaking enhances the device output by filling trap states which form in the dark. For the relatively dynamic LHP semiconductor family, several studies have reported changes in the perovskite trap density following controlled exposures to light.^{100,113–117} Due to features like light-induced ion migrations and compositional redistribution, the underlying mechanisms altering the trap density upon light exposure are still under debate especially when it concerns the effect of the environment (oxygen, water *etc.*) on the process.^{100,113–117} Some studies report a reduction of the overall trap density upon light soaking, due to either annihilation of iodine vacancies and interstitials.¹¹³ Others report a similar response, though connect it with iodine migration.¹¹⁸ On the other hand, light-activated degradation of the device photocurrent has been observed, and subsequently reverses through

a self-healing process when left in the dark.¹⁰⁰ Each of these cases must be considered independently (being strongly dependent on material engineering and processing), making it difficult to set a standard in the stabilization requirement of different devices under working conditions.

Extrinsic defects and traps

Traditional low-temperature solution processing can readily introduce impurities into the crystal bulk during crystallization, attributable to localized stoichiometry deviations. Unintentional contamination of the synthesis solution can also cause substitutional impurities with foreign elements and compounds. An incorporated impurity can promote point doping or lattice vacancies, interstitials and substitutions, which can introduce traps (often relatively deep) into some LHP band structure structures.^{119–121} The exact nature of extrinsic defects arising from synthesis-derived impurities are inherently varied and complex,^{119,122} and are not dealt with here in detail.

Two dominant sources of extrinsic defects in LHP thin films occur at the grain boundaries (GBs) and the terminating surface states, due to the widespread application of grainy spin coated thin films. Examining Table 1 there is a large difference between the trap densities expressed by LHPs in single crystalline and thin film forms. As a clear example, MAPbI₃ single crystals show a much lower defect density (10¹⁰–10¹¹ cm⁻³) than spin coated thin films (10¹⁶–10¹⁷ cm⁻³), a difference directly attributable to extrinsic effects, *i.e.* the introduction of far more relatively disordered surface areas. As a consequence, LHP large single crystals also exhibit much higher carrier mobilities and longer diffusion lengths,¹²³ compared to their polycrystalline counterparts.

The kinds of defects that can form at GBs and on the perovskite surface are far more varied than the intrinsic point defects found in the crystal bulk. The diversity of improper bonding options at GBs and surfaces increases the contribution of parasitic deep traps and nonradiative recombination losses.¹²⁴ Unchecked, deep traps formed at the GB will dramatically destroy solar cell efficiencies. For example, Chen *et al.*¹²⁴ passivated GB traps in thin film MAPbI₃ by releasing the organic species during annealing, resulting in enhanced carrier lifetimes and a dramatic rise in photoconversion efficiencies (from 0.7% to 12%).

Unlike intrinsic point defects which typically require insights from computation modelling, GBs and surface traps can be studied directly using experimental microscopy techniques (often optical- and electron-based), and sorted through effective material processing choices.^{125,126} Through direct observations, it has been discovered that a substantial portion of the total traps accumulates at the grain interface. Edri *et al.*¹²⁷ studied the effect of GBs in MAPbI₃ and reported that the work function energy (*i.e.* energy required to liberate an electron into the conduction band) is higher at the GBs, with the average grain size being controllable through halide substitution/mixing. Also, they found that improper I-I chemical bonds formed at GBs is a consequence of extremely large lattice constant due to large A and B atoms in halide perovskites, a finding supported by first-principle calculations.¹²⁸ On the other hand, studies utilising Kelvin



probe force and conductive atomic force microscopy showed that GBs might actually be helpful for charge carrier separation, because of a potential barrier along the GBs.¹²⁹

Rather than chemically passivating surfaces and GB trap states, several morphology-based techniques have been developed to reduce their effect. For instance, solvent treatment during thermal annealing process can efficiently increase the crystallinity and grain sizes of MAPbI₃¹²⁵ and help seed homogeneous film growth across the substrate, resulting in an almost uninterrupted vertical grain formation.¹³⁰ The formation of vertical grains reduces the projection of the GB surface “seen” by charges being internally screened and extracted by the applied electric field. Combined with a perovskite seeding method, the effect of GBs can be reduced by forming large grain sizes and orienting the crystal grains, to achieve 21.5% power conversion efficiencies.¹³⁰

Surface defects at the heterojunction

The active planar perovskite layer in solar cells forms a heterogeneous junction (heterojunction) on its top and bottom surfaces, where the hole and electron transport layers of the device interface. Both unbound and improperly bound atomic orbitals occur due to a lack of stoichiometric compositions, introducing localised states. When optimising device performance, it is at the perovskite surface where a substantial number of issues regarding carrier trapping and transport,^{131,132} can potentially be improved. This results from the sheer number of different types of defects and trap introduced at heterojunctions. Surface states often provide deep mid-gap traps for charge carriers, resulting in non-radiative recombination pathways and contribute as the main origin of undesirable photocurrent hysteresis effects.^{70,133} Very recently, Jiang *et al.* established¹³⁴ a new record (held briefly) for perovskite solar cell conversion efficiency, certificated at 23.32%. This advance was achieved by the use of an organic halide salt phenethylammonium iodide (PEAI) on HC(NH₂)₂-CH₃NH₃ mixed perovskite films, for the passivation of deep surface traps. Similarly, the concentration of surface trap states was reduced using choline iodide with a new achieved efficiency⁷⁵ in inorganic LHPs at 18.3%. Shao *et al.*⁷⁰ managed to eliminate operational hysteresis by suppressing trap density (on GBs and surface) by fullerene. By controlling the average size of the individual grains, hysteresis effects related to surface traps have also been countered.^{126,135} In the end, studies on the origin of the surface traps in perovskites involving lead iodine complexes point toward undercoordinated I ions being responsible for deep surface traps¹³⁶ (generally depicted in Fig. 2(b)), though further work is required to confirm. Other more exotic solutions have also been shown effective to further decrease surface trap densities; passivating surface traps *via* adsorbates (oxygen, water, thiols), Lewis bases⁷⁴ like pyridine and thiophene (also called ligand treatment passivation), and supramolecular halogen bond complexes.¹³⁶

Hollow perovskites

It is also necessary to discuss the potentially positive effects of defects in MHPs. As we know, there are several ways to tune the bandgap¹⁴⁰ in LHPs including halide doping and changing the

material dimensions from 3D to 2D. The intentional incorporation of small molecules in 3D perovskites (ethylenediammonium¹⁴¹) can promote lead and halide vacancy formation in the 3D structure, creating a less connected perovskite structure and a blue-shift in the direct bandgap.^{141,142} The less dense 3D perovskite is commonly called a hollow perovskite, and provides a fundamentally new way to manipulate perovskite intrinsic properties through defect engineering, without changing dimensionality or halide composition. Most importantly, hollow perovskites exhibit improved air stability¹⁴¹ compared to their unmodified counterparts and allow for efficient solar cells (~17%; Pb/Sn-based). Such efficiencies are only made possible by the fact that the widespread incorporation of defects which hollow out the 3D structure does not introduce large trap-state densities. For example, Ke *et al.*¹⁴³ showed that lead-free perovskite MASnI₃ which is loaded with 15% ethylenediammonium has ~50% lower electron trap-state density than thin films processes without loading, resulting in ~9 times longer carrier lifetime. Similar reductions in trap densities were revealed for the mixed Pb/Sn-based perovskites,¹⁴⁴ indicating that the benefits of this approach can potentially be extended to LHP solar cells.

Lead-free halide perovskites

Because of the toxicity of Pb-based materials and their instability with heat and moisture, Pb-free LHP systems are increasingly being considered for optoelectronic applications, *i.e.* involving elements like Sn, Ge, Bi and Sb. Unlike the beneficial defect tolerance found in the band structure of lead halide perovskites (Fig. 4), Pb-free systems express a very different landscape for defects and specifically charge trapping. For example, Sn-iodide perovskites exhibit an extremely high hole density because of shallow transition levels (selecting for electrons) caused by a high concentration of Sn vacancies.¹⁴⁵ This effect is quite significant, where Sn-based perovskites exhibit exotic self-doping properties, transitioning from semiconductor-like to more metallic.^{146,147} Coincidentally, a similar problem is found in the Ge halide perovskite branch, which also exhibit high hole densities.¹⁴⁸ Double perovskites (general chemical formula A₂BB'X₆) based on trivalent Bi³⁺ and Sb³⁺ exhibit relatively large bandgaps, however generally inferior fundamental properties because of differences related to reduced crystal and electronic symmetry.¹⁴⁹ Although those properties are undesirable for photovoltaic and EL devices, double perovskites exhibit some novel applications, such as high sensitivity X-ray detectors.^{150–152} For instance, Cs₂AgBiBr₆ has been shown to have traps selecting for electrons at room temperature (promoting a p-type nature), which can be significantly suppressed at lower temperatures, while retaining a cubic perovskite symmetry (unlike the APbI₃ systems, which generally undergo a series of symmetry lowering distortions).¹⁵³ For double perovskites, tuning the composition appears to be the main way to reduce the influence of defects in double perovskites.¹⁵⁴ For example, the Ag-rich and Br-poor condition is preferred for n-type Cs₂AgInBr₆ with shallow trap energy level. Similarly, Br-poor/Bi-rich are beneficial for reducing deep energy defects in the Cs₂AgBiBr₆ bulk, the surface extrinsic traps make the dominant contribution of charge recombination in Cs₂AgBiBr₆ photovoltaic devices.



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